Docket: 0756-002428

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT application of)	,
OSAMU NAKAMURA et al)	
Serial No. 10/056,055)	Group Art Unit: 2811
Filed: January 28, 2002).	Examiner: Unassigned
For: SEMICONDUCTOR DEVICE AND)	
MANUFACTURING METHOD OF THE)	
SAME)	

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents Washington, D.C. 20231 Sir:

In accordance with the provisions of 37 C.F.R. 1.56 and 37 C.F.R. 1.97-1.99, Applicant submits herewith a Form PTO-1449 listing references known to Applicant and requests that these references be made of record in the above identified application. Copies of the references listed are submitted herewith in accordance with 37 C.F.R. 1.98(a).

The Commissioner is hereby authorized to charge fees under 37 C.F.R. §§1.16, 1.17, 1.20(a), 1.20(b), 1.20(c), and 1.20(d) (except the Issue Fee) which may be required now or hereafter, or credit any overpayment to Deposit Account No. 50-2280. A duplicate copy of this sheet is attached.

Respectfully submitted,

Eric J. Robinson Robinson Intellectual Property Law Office PMB 955 21010 Southbank Street Potomac Falls, Virginia 20165 (571)434-6789 CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelop addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on 1-23-2003

PTO/SB/08A (08-00)

Approved for use through 10/31/2002. OMB 0651-0031

U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

Substitute for form 1449A/PTO		Complete if Known			
INFORMATION DISCLOSURE			OSTIDE	Application Number	10/056,055
				Filing Date	January 28, 2002
STATEMENT BY APPLICANT		First Named Inventor	Osamu NAKAMURA et al.		
(use as many sheets as necessary)			(נדיי)	Group Art Unit	2811
,		Examiner Name	Unassigned		
Sheet .	1	of	1	Attorney Docket Number	0756-2428

U.S. PATENT DOCUMENTS						
Examiner Initials	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited	Date of Publication of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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			FOREIGN PATENT DOC	UMENTS				
Examiner Initials*	Cite No.1	Foreign Patent Document	Name of Patentee or	Date of Publication of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶		
		Office ³ Number ⁴ (if known)	Applicant of Cited Document	MM-DD-YYYY				
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		Kevin S. Jones et al., "Boron Diffusion Upon Annealing of Laser Thermal Processed Silicon," Ion Implantation Technology 2000, Conference on, 2000, pages 111-114						
		D.J. Llewellyn et al., "Implantation and Annealing of Cu in InP for Electrical Isolation: Microstructural Characterisation," Optoelectronic and Microelectronic Materials and Devices Proceedings, 1996, pages 313-316						

ĺ	Examiner	Date	
	Signature	Considered	·

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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